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# **ROH-037**

# **PCT SECTION**

## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In the U.S. Nationalization Application of PCT/JP00/05596	)
Kazutaka SHIBATA	)
Application No. To Be Assigned	) Attn: Application Branch )
Filed: April 13, 2001	)
For: SEMICONDUCTOR DEVICE AND METHOD FOR MANUFACTURING THE SAME	) )
THE SAME	J

## PRELIMINARY AMENDMENT

Commissioner of Patents Washington, DC 20231

Sir:

Prior to the initial examination, please amend the above-identified application as follows:

## IN THE CLAIMS:

Please rewrite claims 5, 7,9, 12, 15, 20, 21, 24 & 25 as set forth below in clean form. Additionally, in accordance with 37 CFR 1.121(c))(1)(ii), amended claims 5, 7,9, 12, 15, 20, 21, 24 & 25 are set forth in a marked-up version in the pages attached to this Amendment.

- 5. (Amended) A method for manufacturing a semiconductor device as claimed in claim 3, further comprising
  - a step of forming projection electrodes on the surface of the semiconductor substrate